

Patent
Serial No. 10/539,362
Amendment in Reply to Final Office Action of July 25, 2008

**RESPONSE UNDER 37 CFR §1.116
EXPEDITED PROCEDURE
EXAMINING GROUP 1794**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of Atty. Docket : NL 021426

RALPH KURT ET AL. Group Art Unit: 1794

Serial No. 10/539,362 Examiner: ELIZABETH E. MULVANEY

Filed: JUNE 15, 2005 CONF. NO. 7350

**TITLE: USE OF BI-LAYER PHOTOLITHOGRAPHIC RESISTS AS NEW MATERIAL
FOR OPTICAL STORAGE**

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AMENDMENT AFTER FINAL ACTION UNDER 37 C.F.R. §1.116

Sir:

In response to the Final Office Action of July 25, 2008,
please amend the application and consider the remarks as follows: